

Title (en)

PLASMA REACTOR AND ELECTRODE PLATE USED IN THE SAME

Title (de)

PLASMAREAKTOR UND ELEKTRODENPLATTE DAFÜR

Title (fr)

REACTEUR A PLASMA ET PLAQUE D'ELECTRODE UTILISEE DANS CE DERNIER

Publication

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Application

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B01J 19/08

IPC 8 full level

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CPC (source: EP US)

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Citation (search report)

- [X] EP 0431951 A2 19910612 - JAPAN RES DEV CORP [JP]
- [X] WO 02074435 A1 20020926 - ACCENTUS PLC [GB], et al
- See references of WO 2004054703A1

Citation (examination)

US 2002174938 A1 20021128 - XIAOBIN LI BOB [US], et al

Designated contracting state (EPC)

DE FR GB

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